

37 CFR 1.501 INFORMATION DISCLOSURE STATEMENT IN A PATENT (use several sheets if necessary)

Sheet $\underline{1}$ of $\underline{1}$ Serial No.

09/764,950

Applicants Fuchs et al. Filing Date Group Art Unit

Docket No.

P00,1909

			U.S. PA	ATENT DOCUMENTS	January 17,		1762	
Examiner's Initials		Document Number	Date	Name	Class	Subclass	Filing If appro	
0180	AA	3,825,763	07/23/74	Lightenberg et al.				
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			Date	Country		Subclass	Translation	
		Document Number			Class		Yes	N
91BC	AL	OS 198 52 326	11/18/99	Germany				
813C	AM	PS 195 16 450	08/08/96	Germany				
90 KC	AN	PS 42 19 347	05/02/96	Germany				
nge	AO	0 698 932	02/28/96	Europe				<u> </u>
230	AP	0 175 578	12/27/90	Europe				<u> </u>
	ÁQ							
		OTHER PRI	OR ART (Includ	ing Author, Title, Date, Perti	nent Pages, Etc.)			
m B(2)	AR	Vapour-Deposited Csl:Na Layers, I. Morphologic and Crystallographic Properties, Stevels et al., Philips Res. Repts. 29 (1974) 340-352						
: nse	AS	Vapour-Deposited Csl:Na Layers, II. Screens for Application in X-ray Imaging Devices, Stevels et al., Philips Res. Repts. 29 (1974) pp. 353-362						
MBC	AT	Computersimulation des Photonentransports in Csl-Eingangsschirmen von Röntgenbildverstärkern, Eckenbach, Unser Forschung in Deutschland (Philips) Vol. IV (1989) pp 51-53						
901 BC	.AU	Effect of the Mobility of Metal Atoms on the Structure of Thin Films Deposited at Oblique Incidence, van de Waterbeemd et al., Philips Res. Repts. Vol. 22 (1967) pp. 375-387						
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	AW							
	AX							
	AY							
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.